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(54) **VAPOR CELL ATOMIC CLOCK PHYSICS PACKAGE**

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See application file for complete search history.

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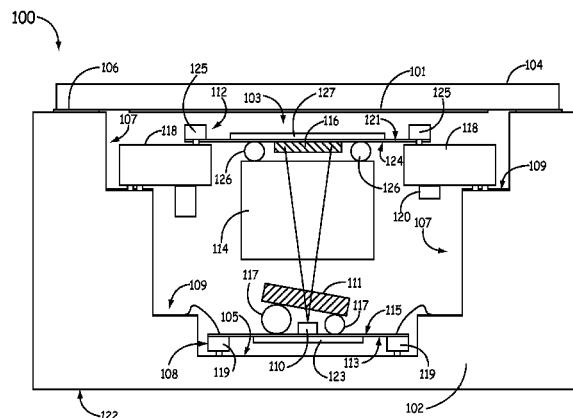
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(57) **ABSTRACT**

In an example, a chip-scale atomic clock physics package is provided. The physics package includes a body defining a cavity having a base surface and one or more side walls. The cavity includes a first step surface and a second step surface defined in the one or more side walls. A first scaffold mounted to the base surface in the cavity. One or more spacers defining an aperture therethrough are mounted to the second step surface in the cavity. A second scaffold is mounted to a first surface of the one or more spacers spans across the aperture of the one or more spacers. A third scaffold is mounted to a second surface of the one or more spacers in the cavity and spans across the aperture of the one or more spacers. Other components of the physics package are mounted to the first, second, and third scaffold.

**20 Claims, 5 Drawing Sheets**



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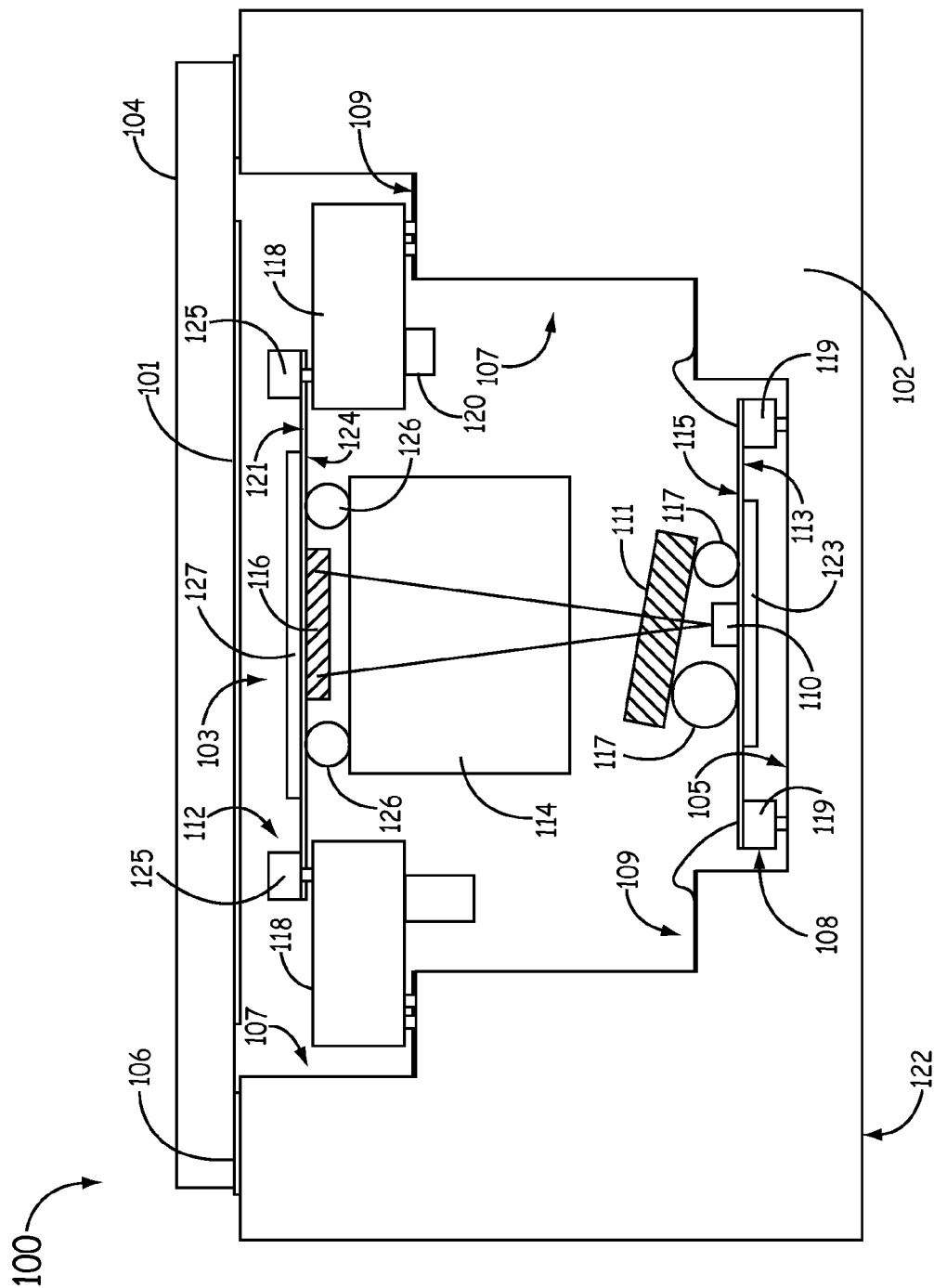
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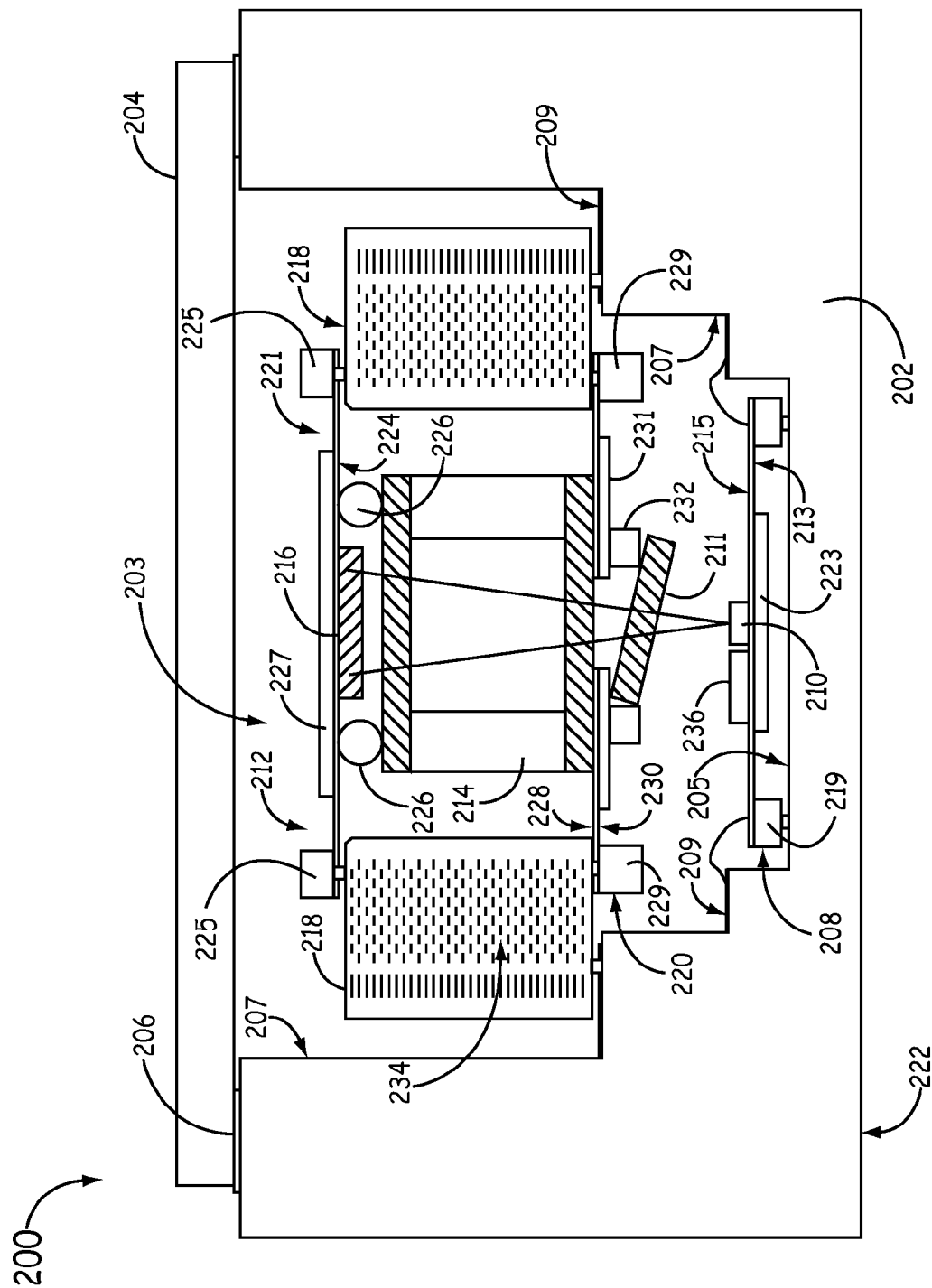


FIG. 2

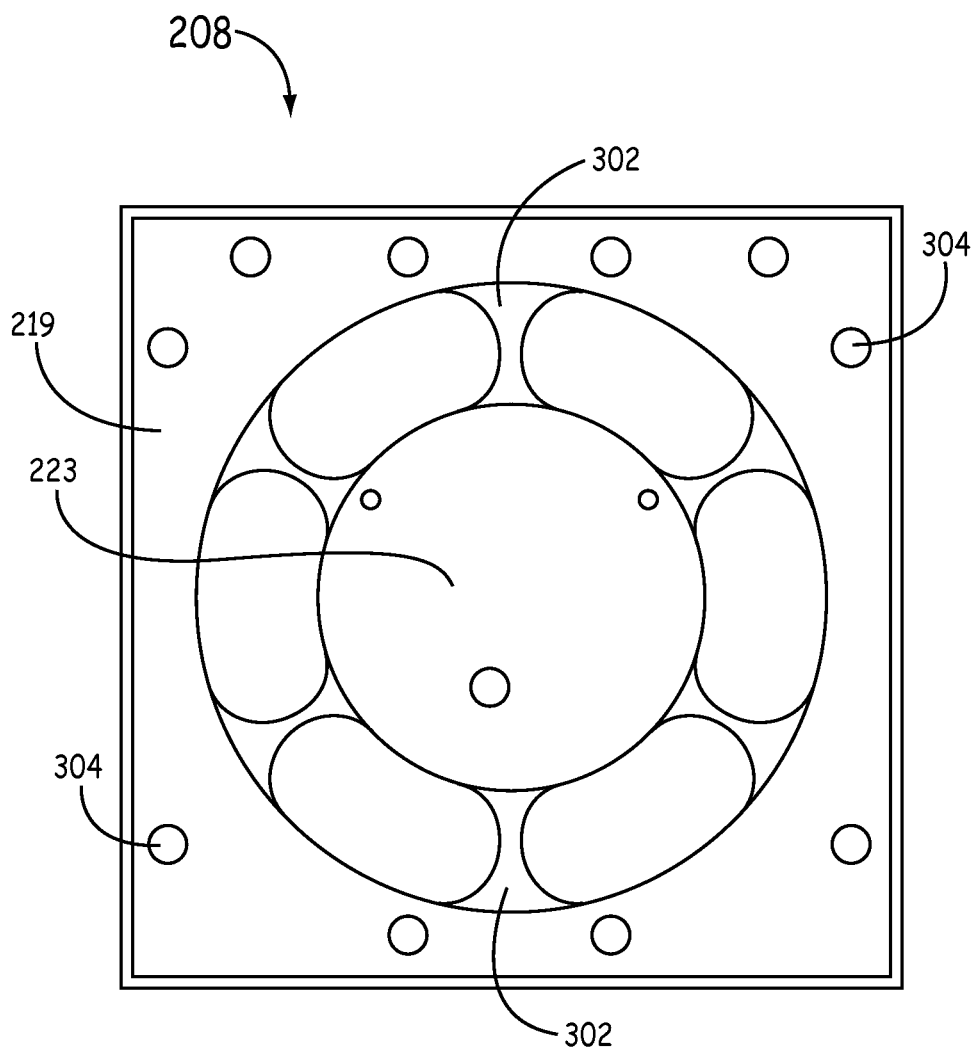


FIG. 3

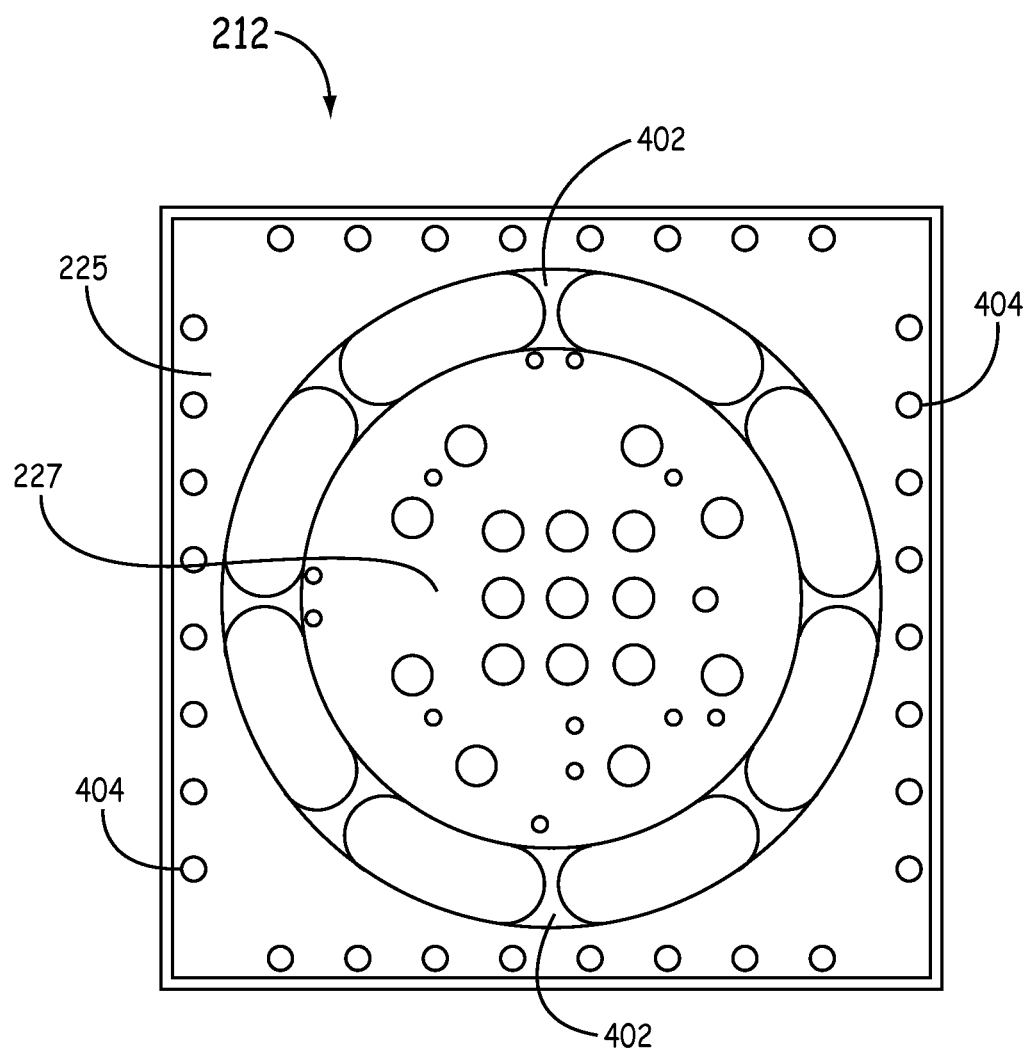


FIG. 4

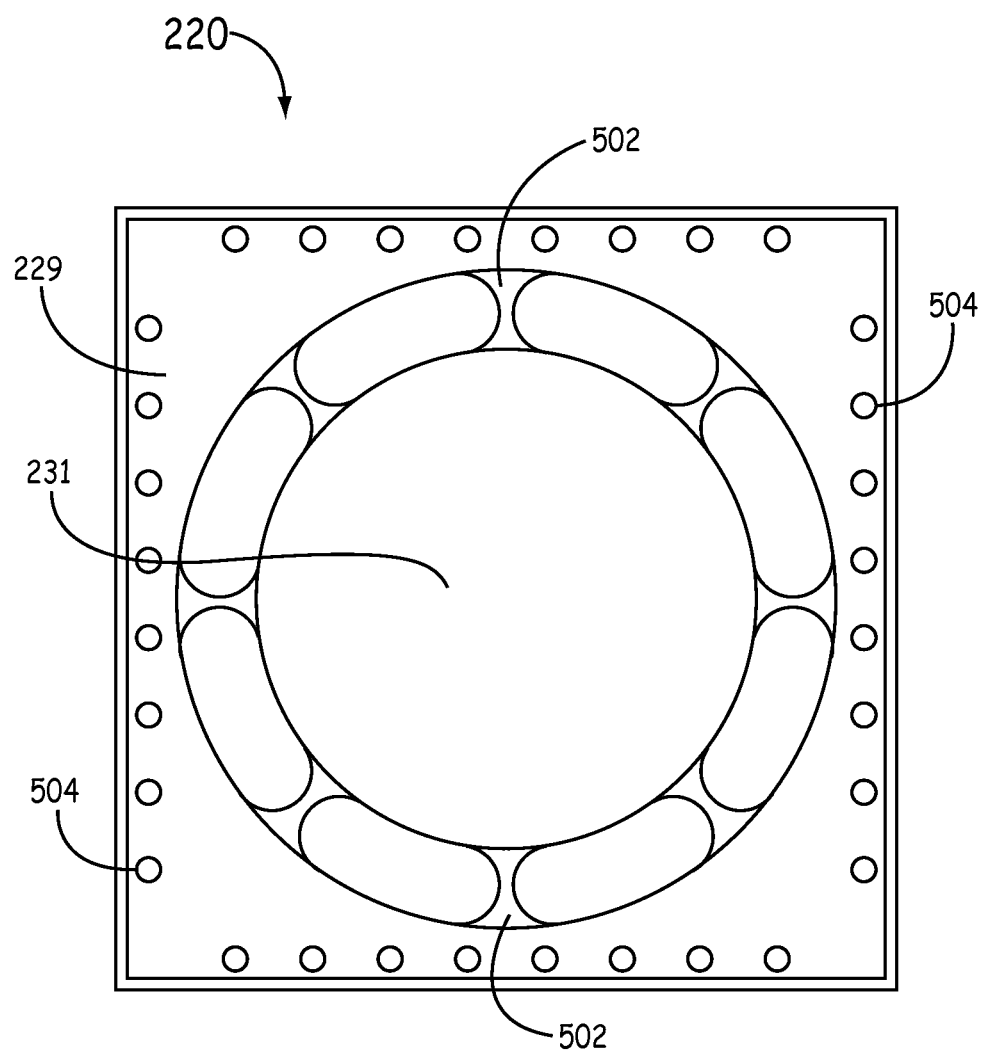


FIG. 5

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## VAPOR CELL ATOMIC CLOCK PHYSICS PACKAGE

### CROSS-REFERENCE TO RELATED APPLICATIONS

This application is a continuation of U.S. application Ser. No. 13/327,417, filed on Dec. 15, 2011 and claims the benefit of priority to U.S. Provisional Application No. 61/496,517, filed on Jun. 13, 2011, the disclosures of which are hereby incorporated herein by reference.

### STATEMENT REGARDING FEDERALLY SPONSORED RESEARCH OR DEVELOPMENT

This invention was made with Government support under W15P7T-10-C-B025 awarded by the US Army. The Government has certain rights in the invention.

### BACKGROUND

A physics package for a chip-scale atomic clock can include a laser, waveplate, vapor cell, and a photodetector along with other associated electronics. These components can be housed within a body that can be hermetically seal to create a vacuum within the body.

### SUMMARY

In an example, a chip-scale atomic clock physics package is provided. The physics package includes a body defining a cavity having a base surface and one or more side walls. The cavity includes a first step surface and a second step surface defined in the one or more side walls. A first scaffold mounted to the base surface in the cavity. One or more spacers defining an aperture therethrough are mounted to the second step surface in the cavity. A second scaffold is mounted to a first surface of the one or more spacers spans across the aperture of the one or more spacers. A third scaffold is mounted to a second surface of the one or more spacers in the cavity and spans across the aperture of the one or more spacers. Other components of the physics package are mounted to the first, second, and third scaffold.

### DRAWINGS

Understanding that the drawings depict only exemplary embodiments and are not therefore to be considered limiting in scope, the exemplary embodiments will be described with additional specificity and detail through the use of the accompanying drawings, in which:

FIG. 1 is a cross-sectional view of an example of a vapor cell atomic clock physics package.

FIG. 2 is a cross-sectional view of another example of a vapor cell atomic clock physics package.

FIG. 3 is a bottom view of an example lower scaffold of the vapor cell atomic clock physics package of FIG. 2.

FIG. 4 is a top view of an example upper scaffold of the vapor cell atomic clock physics package of FIG. 2.

FIG. 5 is a bottom view of an example middle scaffold of the vapor cell atomic clock physics package of FIG. 2.

In accordance with common practice, the various described features are not drawn to scale but are drawn to emphasize specific features relevant to the exemplary embodiments.

### DETAILED DESCRIPTION

In the following detailed description, reference is made to the accompanying drawings that form a part hereof, and in

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which is shown by way of illustration specific illustrative embodiments. However, it is to be understood that other embodiments may be utilized and that logical, mechanical, and electrical changes may be made. Furthermore, the method presented in the drawing figures and the specification is not to be construed as limiting the order in which the individual steps may be performed. The following detailed description is, therefore, not to be taken in a limiting sense.

FIG. 1 is a cross-sectional view of an example physics package for a chip-scale atomic clock (CSAC) physics package **100**. The CSAC physics package **100** can include a ceramic body **102** defining a cavity **103** for housing components of the CSAC physics package **100**. The ceramic body **102** including the components in the cavity **103** can comprise a ceramic leadless chip carrier (CLCC) package. The CSAC physics package **100** can also include a non-magnetic (e.g., ceramic) lid **104** configured to fit over the cavity **103** of the ceramic body **102** to form a closed package encasing the cavity **103** and the components therein. In an example, the ceramic lid **104** has a generally planar shape. A solder seal **106** can be used to seal the lid **104** to the body **102**. In an example, the lid **104** can be sealed to the body **102** in a vacuum. In an example, die attach and sealing operations for the CSAC physics package **100** (e.g., for sealing the lid **104** to the body **102**) are accomplished without the use of flux to enable low pressure in the sealed package which can enable lower power operation. This physics package can enable batch vacuum sealing of the lid **104** to the body **102**. The CSAC physics package **100** can also include a getter film **101** coating most of the interior surface of a ceramic lid **104**.

In an example, the ceramic body **102** has one side (e.g., the top) open such that the body **102** defines the cavity **103**. The lid **104** can cover the open side of the body **102** to enclose the cavity **103**. In an example, the cavity **103** has a shape generally pentagonal cross section when viewed from the open side (e.g., top). In another example, the cavity **103** has a generally circular cross-section when viewed from the open side (e.g., top). In any case, the cavity **103** can include a base surface **105** and one or more interior sides **107**. The one or more sides **107** can have one or more steps **109** defined therein for, for example, supporting structures within the cavity of the body **102**.

The CSAC physics package **100** can include one or more scaffolds **108**, **112** for supporting components such as a laser **110**, waveplate **111**, vapor cell **114**, and photodetector **116**. In an example, a scaffold **108**, **112** can include a membrane suspended within a frame. The scaffolds **108**, **112** can also include a stiffening member attached to the membrane to provide additional structure for the membrane. To produce the scaffolds **108**, **112** at a size that can be used for the CSAC physics package **100**, the scaffolds **108**, **112** can be fabricated using semiconductor fabrication processes. Accordingly, the frame and stiffening member can be composed of silicon and the membrane can be composed of polyimide. The polyimide can thermally isolate the stiffening member and components on the scaffolds **108**, **112** from the frame and body **102**.

The CSAC physics package **100** includes a lower scaffold **108** and an upper scaffold **112** that are mounted in the cavity **103**. In an example, the lower scaffold **108** and the upper scaffold **112** can be disposed parallel to one another and parallel to the base surface **105** of the cavity **103**. In this example, the lower scaffold **108** is attached to the base surface **105** of the cavity **103** via a fluxless die attach. In an example, the fluxless die attach can be a plurality of gold (Au) stud bumps. The lower scaffold **108** can function as a support structure for a heater, the laser **110**, and the waveplate **111**. The lower scaffold **108** and components thereon (e.g., laser



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110, waveplate 111) can be electrically coupled to pins on the body 102 via wire bonds to a pad on a lower step 109 of the inner side surface 107 of the cavity 103 of the ceramic body 102.

The lower scaffold 108 can include a first side 113 that opposes the base surface 105 and a second side 115 that is reverse of the first side 113 and facing the lid 104 and the upper scaffold 112. In an example, the frame 119 and the stiffening member 123 are on the first side 113. The stiffening member 123 can define a plurality of apertures to reduce the mass thereof. In an example, the laser 110 and the waveplate 111 are mounted to the second side 115. Moreover, the waveplate 111 can be disposed overtop of the laser 110 such that a beam of the laser 110 propagates through the waveplate 111. In an example, the laser 110 can be solder bonded to the second side 115 using, for example, flip-chip mounting. Additionally, a plurality of solder balls 117 can be attached to the second side 115. The plurality of solder balls 117 can be disposed around the laser 110 and project a height above the second side 115 that is higher than the laser 110 such that the waveplate 111 can be soldered to the plurality of solder balls 117 and disposed overtop of the laser 110. In an example, the plurality of solder balls 117 can be formed using a jetting process tuned to produce solder balls of the desired size. In an example, the solder balls 117 can be formed of a solder having a high temperature melting point, such that, once formed on the scaffold 108, the solder balls 117 generally maintain their structure during further fabrication of the CSAC physics package 100.

In an example, a first portion of the solder balls 117 on the second side 115 have a lower height above the second side 115 than a second portion of the solder balls 117. Moreover, the first portion of solder balls 117 can be disposed to attach about a first edge of the waveplate 111 and a second portion of the solder balls 117 can be disposed to attach about a second edge of the waveplate 111. The differing height of the first and second portions of the solder balls 117 can cause the waveplate 111 to be disposed at an angle with respect to the second side 115. Orienting the waveplate 111 at an angle can direct laser reflections off of the waveplate 111 away from the laser 110. In an example, the laser 110 can be a vertical cavity surface emitting laser (VCSEL). In an example, the waveplate 111 can be a quarter waveplate.

In an example, the upper scaffold 112 can function as a support structure for an alkali vapor cell 114 and a photodetector 116. The upper scaffold 112 can be supported on an upper step 109 (e.g., an upper shelf) of the inner side surface 107 of the cavity 103 of the ceramic body 102. Moreover, by forming steps 109 in the sides 107 of the cavity 103, the body 102 can be used to, at least partially, space the upper scaffold 112 from the lower scaffold 108. In an example, the upper scaffold 112 can be attached to one or more spacers 118 (e.g., leg structures, washer) extending up from the upper step 109 of the cavity 103 to further space the upper scaffold 112 from the lower scaffold 108. In an example, the spacer 118 can be composed of ceramic. In an example, the spacer 118 can have a ring shape (e.g., a pentagon ring shape) defining an aperture therein. The spacer 118 can be disposed around the vapor cell 114 such that the vapor cell 114 is within the aperture defined in the spacer 118.

In an example, the spacer 118 can function to reduce fatigue on the joint(s) coupling the upper scaffold 112 to the upper step 109. The spacer 118 can reduce fatigue by being composed of a material that has a thermal expansion coefficient that is in between the thermal expansion coefficient of the body 102 and the thermal expansion coefficient of the upper scaffold 112. Accordingly, as the body 102 and the

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upper scaffold 112 expand and contract due to temperature changes, the spacer 118 can absorb some of the changes. For example, the body 102 can be composed of a ceramic having a thermal expansion coefficient of 7 ppm per degree Celsius, the spacer 118 can have a thermal expansion coefficient of 5 ppm per degree Celsius, and the upper scaffold 112 can have a thermal expansion coefficient of 3 ppm per degree Celsius. In another example, the spacer 118 can be formed of the same material as the body 102 and the lid 104. The spacer 118 can provide mechanical support and electrical contact for the upper scaffold 112. In some examples, the spacer 118 can also provide mechanical support and electrical contact for additional electronic components such as surface mount technology (SMT) electronics 120.

The combination of the upper scaffold 112 and the ceramic spacer 118 can traverse the cavity 103 of the body 102 and attach to the upper step 109. In an example, the upper scaffold 112 can be attached to the spacer 118 via fluxless die attach. The spacer 118 can be attached via fluxless die attach to the body 102, for example, at the upper step 109 of the body 102. In an example, the fluxless die attach can be a plurality of gold (Au) stud bumps.

The upper scaffold 112 can include a first side 121 that opposes the lid 104 and a second side 124 that is reverse of the first side 121 and facing the lower scaffold 108. In an example, the frame 125 and the stiffening member 127 are on the first side 121. The stiffening member 127 can define a plurality of apertures to reduce the mass thereof. In an example, the photodetector 116 and the vapor cell 114 are mounted to the second side 124. Moreover, the vapor cell 114 can be disposed overtop of the photodetector 116 and aligned with the laser 110 and waveplate 111 such that a beam from the laser 110 propagates through the waveplate 111, then through the vapor cell 114 and can be detected by the photodetector 116. In an example, the photodetector 116 can be solder bonded to the second side 124 using, for example, flip-chip mounting. A plurality of solder balls 126 can be attached to the second side 124. The plurality of solder balls 126 can be disposed around the photodetector 116 and can project a height above the second side 124 that is higher than the photodetector 116 such that the vapor cell 114 can be soldered to the plurality of solder balls 126 and disposed overtop of the photodetector 116. In an example, the vapor cell 114 can be disposed at least 200 micrometers apart from the photodetector 116. This gap can enable flux to be flushed from between the vapor cell 114 and the photodetector 116. In an example, the plurality of solder balls 126 can be formed using a jetting process tuned to produce solder balls of the desired size. In an example, the solder balls 126 can be formed of a solder having a high temperature melting point, such that, once formed on the scaffold 112, the solder balls 126 generally maintain their structure during further fabrication of the CSAC physics package 100. In an example, the vapor cell 114 can be an alkali vapor cell containing rubidium atoms.

In an example, the upper scaffold 112 is in a flipped position with respect to the lower scaffold 108. That is, the frame 119 of the lower scaffold 108 projects in the opposite direction from the frame 125 of the upper scaffold 112. Additionally, the components (e.g., laser 110, waveplate 111, and photodetector 116, vapor cell 114) are on the side of their respective scaffold 108, 112 that is the reverse of the side having the frame 119, 125. Accordingly, in order to mount the scaffolds 108, 112 with the components all within the space between the scaffolds 108, 112, the scaffolds are disposed in a flipped position with respect to one another. Additionally, the components (e.g., the laser 110, waveplate 111, photode-

tector 116, and vapor cell 114) can be disposed in between the polyimide layers of the scaffolds 108, 112.

The CSAC physics package 100 can include an input/output (I/O) solder pad 122 on a bottom portion of the body 102. Thus, wires can attach to the CSAC physics package 100 on a bottom portion thereof. In an example, interconnects between the I/O solder pad 122 and internal components (e.g., laser 110, waveplate 111, and photodetector 116, vapor cell 114) can be routed through the body 102. In some examples, interconnects for components on the upper scaffold 112 (e.g., photodetector 116) can be routed through the spacer 118. Thus, the spacer 118 can include electrical traces on an internal or outside portion thereof.

In an example, a magnetic coil can be disposed about (e.g., within) the spacer 118 such that the magnetic coil extends around the vapor cell 114. The magnetic coil can be configured to provide a bias field for the vapor cell 114. In an example, the magnetic coil can be integrated into (e.g., internal to) the spacer 118.

FIG. 2 is a cross-sectional view of another example physics package for a CSAC physics package 200. The CSAC physics package 200 can include a ceramic body 202 defining a cavity 203 for housing components of the CSAC physics package 200. The ceramic body 202 including the components in the cavity 203 can comprise a ceramic leadless chip carrier (CLCC) package. The CSAC physics package 200 can also include a non-magnetic (e.g., ceramic) lid 204 configured to fit over the cavity 203 of the ceramic body 202 to form a closed package encasing the cavity 203 and the components therein. In an example, the ceramic lid 204 has a generally planar shape. A solder seal 206 can be used to seal the lid 204 to the body 202. In an example, die attach and sealing operations for the CSAC physics package 200 (e.g., for sealing the lid 204 to the body 202) are accomplished without the use of flux to enable low pressure in the sealed package which can enable lower power operation. In an example, the lid 204 can be sealed to the body 202 in a vacuum. This physics package can enable batch vacuum sealing of the lid 204 to the body 202. The CSAC physics package 200 can also include a getter film coating most of the interior surface of a ceramic lid 204.

In an example, the ceramic body 202 has one side (e.g., the top) open such that the body 202 defines the cavity 203. The lid 204 can cover the open side of the body 202 to enclose the cavity 203. In an example, the cavity 203 has a shape generally pentagonal cross section when viewed from the open side (e.g., top). In another example, the cavity 203 has a generally circular cross-section when viewed from the open side (e.g., top). In any case, the cavity 203 can include a base surface 205 and one or more interior sides 207. The one or more sides 207 can have one or more steps 209 defined therein for, for example, supporting structures within the cavity of the body 202.

The CSAC physics package 200 can include one or more scaffolds 208, 212, 220 for supporting components such as a laser 210, waveplate 211, vapor cell 214, and photodetector 216. In an example, a scaffold 208, 212, 220 can include a membrane suspended between a frame. The scaffolds 208, 212, 220 can also include a stiffening member attached to the membrane to provide additional structure for the membrane. To produce the scaffolds 208, 212, 220 at a size that can be used for the CSAC physics package 200, the scaffolds 208, 212, 220 can be fabricated using semiconductor fabrication processes. Accordingly, the frame and stiffening member can be composed of silicon and the membrane can be composed of polyimide. The polyimide can thermally isolate the stiffening member and components on the scaffolds 208, 212, 220 from the frame and body 202.

The CSAC physics package 200 includes a lower scaffold 208, an upper scaffold 112, and a middle scaffold 220 that are mounted in the cavity 203. In an example, the lower scaffold 208, the upper scaffold 212, and the middle scaffold 220 can be disposed parallel to one another and parallel to the base surface 205 of the cavity 203. In this example, the lower scaffold 208 is attached to the base surface 205 of the cavity 203 via fluxless die attach. In an example, the fluxless die attach can be a plurality of gold (Au) stud bumps. The lower scaffold 208 can function as a support structure for a heater and the laser 210. The lower scaffold 208 and components thereon (e.g., laser 210) can be electrically coupled to pins on the body 202 via wire bonds to a pad on a lower step 209 of the inner side surface 207 of the cavity 203 of the ceramic body 202. In an example, the laser 210 can be a vertical cavity surface emitting laser (VCSEL).

The lower scaffold 208 can include a first side 213 that opposes the base surface 205 and a second side 215 that is reverse of the first side 213 and facing the lid 204, the middle scaffold 220, and the upper scaffold 212. In an example, the frame 219 and the stiffening member 223 are on the first side 213. The stiffening member 223 can define a plurality of apertures to reduce the mass thereof. In an example, the laser 210 is mounted to the second side 215. In an example, the laser 210 can be solder bonded to the second side 215 using, for example, flip-chip mounting.

FIG. 3 is a bottom view of an example lower scaffold 208. As mentioned above, the lower scaffold 208 can include a membrane having a frame 219 and a stiffening member 223 attached thereto. The frame 219 and the stiffening member 223 can be separated from one another on the membrane with a plurality of tethers 302 of the membrane extending between the frame 219 and the stiffening member 223. A plurality of stud bumps 304 can be on the frame 219 to attach the frame 219 to the body 202. Components (e.g., the laser 210) can be mounted on the membrane in the area of the stiffening member 223. Traces can extend across the tethers 302 to electrically couple the components on the stiffening member to the stud bumps 304.

The upper scaffold 212 and middle scaffold 220 can be mounted on opposite sides of one or more spacers 218 (e.g., leg structure, washer). The upper scaffold 212 can function as a support structure for the photodetector 216 and the middle scaffold 220 can function as a support structure for the waveplate 211. In addition, the upper scaffold 212 and middle scaffold 220 can function as a support structure for the alkali vapor cell 214. In particular, the vapor cell 214 can be supported between the upper scaffold 212 and the middle scaffold 220. Accordingly, the vapor cell 214 attached to the upper scaffold 212 on one end and the middle scaffold 220 on the opposite end. Moreover, the vapor cell 214 can be disposed within an aperture of the spacer 218. Accordingly, the upper scaffold 212, middle scaffold 220, and the spacer 218 can form a support structure for the vapor cell 214. In an example, a heater for the upper surface of the vapor cell 214 can be mounted on the upper scaffold 212 and a heater for the lower surface of the vapor cell 214 can be mounted on the middle scaffold 220. In another example, one or more heaters can be fabricated on one or more surfaces of the vapor cell 214. In an example, the spacer 218 can have a ring shape (e.g., a pentagon ring shape) defining an aperture therein. The spacer 218 can be disposed around the vapor cell 214 such that the vapor cell 214 is within the aperture defined in the spacer 218.

In an example, the spacer 218 can also function to reduce fatigue on the joint(s) coupling the upper scaffold 212 and the middle scaffold 220 to the upper step 209. The spacer 218 can

reduce fatigue by being composed of a material that has a thermal expansion coefficient that is in between the thermal expansion coefficient of the body 202 and the thermal expansion coefficient of the upper scaffold 212 and middle scaffold 220. Accordingly, as the body 202, the upper scaffold 212, and the middle scaffold 220 expand and contract due to temperature changes, the spacer 218 can absorb some of the changes. For example, the body 202 can be composed of a ceramic having a thermal expansion coefficient of 7 ppm per degree Celsius, the spacer 218 can have a thermal expansion coefficient of 5 ppm per degree Celsius, and the upper scaffold 212 and middle scaffold 220 can have a thermal expansion coefficient of 3 ppm per degree Celsius. In another example, the spacer 218 can be formed of the same material as the body 202 and the lid 204. The spacer 218 can provide mechanical support and electrical contact for the upper scaffold 212 and middle scaffold 220. In some examples, the spacer 218 can also provide mechanical support and electrical contact for additional electronic components such as surface mount technology (SMT) electronics.

As mentioned above, the spacer 218 with the upper scaffold 212 and middle scaffold 220 mounted thereon can be mounted to a step 209 in the body 202. In particular, the spacer 218 can be mounted to an upper step 209. Steps 209 in the sides 209 of the cavity 203 can be used to, at least partially, space the upper scaffold 212 and middle scaffold 220 from the lower scaffold 208. The spacer 218 can extend up from the upper step 209 of the cavity 203 to further space the upper scaffold 212 from the lower scaffold 208 and middle scaffold 220 and provide space for the vapor cell 214 between the middle scaffold 220 and the upper scaffold 214. In an example, the spacer 218 can be composed of ceramic.

The combination of the upper scaffold 212 and the ceramic spacer 218 can traverse the cavity 203 of the body 202 on a top portion of the spacer 218. Likewise, the middle scaffold 220 and the ceramic spacer 218 can traverse the cavity 203 of the body 202 on a bottom portion of the spacer 218. In an example, the upper scaffold 212 and the middle scaffold 220 can be attached to the spacer 218 via fluxless die attach. The spacer 218 can be attached via fluxless die attach to the upper step 209 of the body 202. In an example, the fluxless die attach can be a plurality of gold (Au) stud bumps.

The upper scaffold 212 can include a first side 221 that opposes the lid 204 and a second side 224 that is reverse of the first side 221 and facing the middle scaffold 220 and the lower scaffold 208. In an example, the frame 225 and the stiffening member 227 are on the first side 221. The stiffening member 227 can define a plurality of apertures to reduce the mass thereof. In an example, the photodetector 216 and the vapor cell 214 are mounted to the second side 224. Moreover, the vapor cell 214 can be disposed overtop of the photodetector 216 and aligned with the laser 210 and waveplate 211 such that a beam from the laser 210 propagates through the waveplate 211, then through the vapor cell 214 and can be detected by the photodetector 216. In an example, the photodetector 216 can be solder bonded to the second side 224 using, for example, flip-chip mounting. A plurality of solder balls 226 can be attached to the second side 224. The plurality of solder balls 226 can be disposed around the photodetector 216 and can project a height above the second side 224 that is higher than the photodetector 216 such that the vapor cell 214 can be soldered to the plurality of solder balls 224 and disposed overtop of the photodetector 216. In an example, the vapor cell 214 can be disposed at least 200 micrometers apart from the photodetector 216. This gap can enable flux to be flushed from between the vapor cell 214 and the photodetector 216. In an example, the plurality of solder balls 226 can be formed

using a jetting process tuned to produce solder balls of the desired size. In an example, the solder balls 226 can be formed of a solder having a high temperature melting point, such that, once formed on the scaffold 212, the solder balls 224 generally maintain their structure during further fabrication of the CSAC physics package 200. In an example, the vapor cell 214 can be an alkali vapor cell containing rubidium atoms.

In an example, the upper scaffold 212 is in a flipped position with respect to the lower scaffold 208 and the middle scaffold 220. That is, the frame 219 on the lower scaffold 208 and the middle scaffold 220 project in the opposite direction from the frame 225 of the upper scaffold 212. Additionally, the vapor cell 214 can be disposed in between the polyimide layers of the upper scaffold 212 and middle scaffold 220.

FIG. 4 is a top view of an example upper scaffold 212. As mentioned above, the upper scaffold 212 can include a membrane having a frame 225 and a stiffening member 227 attached thereto. The frame 225 and the stiffening member 227 can be separated from one another on the membrane with a plurality of tethers 402 of the membrane extending between the frame 225 and the stiffening member 227. A plurality of stud bumps 404 can be on the frame 225 to attach the frame 225 to the body 202. Components (e.g., the vapor cell 214) can be mounted on the membrane in the area of the stiffening member 227. Traces can extend across the tethers 402 to electrically couple the components on the stiffening member to the stud bumps 404.

The middle scaffold 220 can include a first side 228 that faces the lid 204 and opposes the upper scaffold 212 and a second side 230 that faces the base surface 205 and opposes the lower scaffold 208. The middle scaffold 220 can be mounted to the spacer 218 on the first side 228 of the scaffold 220.

In an example, the frame 229 and the stiffening member 231 are on the second side 230. The stiffening member 231 can define a plurality of apertures to reduce the mass thereof. The vapor cell 214 can also be mounted on the first side 228 of the middle scaffold 220. The waveplate 211 can be mounted on the second side 230 of the middle scaffold 220. In an example, a plurality of tilting features 232 can be fabricated into the second side 230 of the middle scaffold 220. The waveplate 211 can be mounted to these tilting features 232, which can be configured to orient the waveplate 211 at an angle with respect to the middle scaffold 220. For example, a first feature can have a lower height than a second feature, and a first edge of the waveplate 211 can be attached to the first feature and a second edge of the waveplate 211 can be attached to the second feature. Orienting the waveplate 211 at an angle can direct laser reflections off of the waveplate 211 away from the laser 210. In an example, the waveplate 211 can be a quarter waveplate.

FIG. 5 is a bottom view of an example middle scaffold 220. As mentioned above, the middle scaffold 220 can include a membrane having a frame 229 and a stiffening member 231 attached thereto. The frame 229 and the stiffening member 231 can be separated from one another on the membrane with a plurality of tethers 502 of the membrane extending between the frame 229 and the stiffening member 231. A plurality of stud bumps 504 can be on the frame 229 to attach the frame 229 to the body 202. Components (e.g., the vapor cell 214) can be mounted on the membrane in the area of the stiffening member 223. Additionally, other components (e.g., the waveplate 211) can be mounted on the stiffening member 231.

In an example, a magnetic coil 234 can be disposed about (e.g., within) the spacer 218 such that the magnetic coil extends around the vapor cell 214. The magnetic coil can be

configured to provide a bias field for the vapor cell **214**. In an example, the magnetic coil **234** can be integrated into (e.g., internal to) the spacer **218**.

In an example, a second photodetector **236** can be configured to detect reflections of the laser **210** from the waveplate **211**. The second photodetector **236** can be used to control the light power output of the laser **210**. In particular, based on the strength of the light reflected from the waveplate **211**, the power output of the laser **210** can be determined and controlled accordingly. The second photodetector **236** can be mounted to the lower scaffold **208**. In particular, the second photodetector **236** can be mounted to the second side **215** of the lower scaffold **208** adjacent the laser **210**.

The CSAC physics package **200** can include an input/output (I/O) solder pad **222** on a bottom portion of the body **202**. Thus, a bottom portion of the CSAC physics package **200** can be attached to a circuit board. In an example, interconnects between the I/O solder pad and internal components (e.g., laser **210**, waveplate **211**, and photodetector **216**, vapor cell **214**) can be routed through the body **202**. In some examples, interconnects for components on the upper scaffold **212** (e.g., photodetector **216**) and middle scaffold **220** (e.g., heater) can be routed through the spacer **218**. Thus, the spacer **218** can include electrical traces on an internal or outside portion thereof.

In an example, to manufacture the CSAC physics package **100** or CSAC physics package **200**, the scaffolds, spacer, body, and lid can be formed and combined together. The scaffolds can be created and assembled at the wafer level. For example, a scaffold can comprise a silicon wafer having a polyimide membrane on a first side thereof. The side of the scaffold having the polyimide member can be referred to as the “front side” of the scaffold. The front side of the scaffold can then be etched to form the frame and stiffening member having holes therein. As mentioned above, adding the polyimide membrane and etching the scaffold can occur on wafer having a plurality of un-diced scaffold dies thereon.

Once etched, components can be attached to the scaffold. For the lower scaffold **108** of the CSAC physics package **100**, the etched wafer can have the heater, laser **110**, and waveplate **111** attached thereto. The laser **110** and heater can be, for example, flip-chip mounted to the lower scaffold **108**. The plurality of solder balls **117** can be attached using the jetting process mentioned above. Then, the waveplate **111** can be attached to the solder balls **117** using a solder, an epoxy, or other die attach compound. For the upper scaffold **112**, the etched wafer can have the photodetector **116** attached thereto, along with the solder balls **126**, and then the vapor cell **114**. The photodetector **116** can be flip-chip mounted, and the vapor cell **114** can be attached using a solder, an epoxy, or other die attach compound. In an example, the photodetector **116** can be electrically coupled to the upper scaffold **112** with a wirebond.

For the lower scaffold **208** of the CSAC physics package **200**, the etched wafer can have the laser **210** and the second photodetector **236** attached thereto. The laser **210** and second photodetector **236** can be, for example, flip-chip mounted to the lower scaffold **208**. For the middle scaffold **220**, the plurality of features **232** can be fabricated therein using standard semiconductor processes. The waveplate **211** can then be attached to the scaffold **220** (e.g., to the plurality of features **232**) using, for example, an epoxy. For the upper scaffold **212**, the etched wafer can have the photodetector **216** attached thereto, along with the solder balls **226**, and then the vapor cell **214**. The photodetector **216** can be flip-chip mounted, and the vapor cell **214** can be attached using a solder, an epoxy, or other die attach compound. In an

example, the photodetector **216** can be electrically coupled to the upper scaffold **212** with a wirebond.

These components can be added before singulation of the wafers. The wafers can then be singulated to form the individual scaffolds. In an example, the wafers can be singulated using a dry dicing process. The scaffolds can then have solder balls attached for electrical and mechanical attachment of the scaffolds. In an example, after the scaffolds have been fabricated they can be tested and have operational burn-in performed.

The lower scaffold **108** of the CSAC physics package **100** can be attached to the base surface **105** (e.g., bottom, floor) of the body **102** using fluxless die attach (e.g., gold (Au) stud bumps). Wirebonds for the lower scaffold **108** can be attached to the appropriate pads on the body **102** at, for example, the lower step **109**. The upper scaffold **112** can be attached to spacer **118** or directly to the body **102** using solder, gold (Au) stud bumps, or other fluxless die attach compounds.

The SMT electronics **120** can be attached to the spacer **118**. The spacer **118** can be manufactured in array form suitable for batch die/component attach, and singulated to separate. The spacer **118** can be singulated, the upper scaffold **112** can be attached, and the combination can be attached to the upper step **109** in the body **102** using fluxless die attach (e.g., gold (Au) stud bumps). In an example, this die attach can provide both mechanical and electrical feedthru. In another example, this die attach can provide mechanical die attach with no electrical feedthru and the electrical attach can be done with wirebonds.

The lower scaffold **208** of the CSAC physics package **200** can be attached to the base surface **205** (e.g., bottom, floor) of the body **202** using fluxless die attach (e.g., gold (Au) stud bumps). Wirebonds for the lower scaffold **208** can be attached to the appropriate pads on the body **202** at, for example, the lower step **209**.

The spacer **218** can be manufactured in array form suitable for batch die/component attach, and singulated to separate. Once singulated, the upper scaffold **212** and the middle scaffold **220** can be attached to opposite ends of the spacer **218**. The vapor cell **214** can be positioned in between the upper scaffold **212** and the middle scaffold **220** in an aperture formed by the spacer **218**. The vapor cell **214** can be attached to the middle scaffold **220** and/or the upper scaffold **212** if not already attached. The upper scaffold **212** and middle scaffold **220** can be attached to spacer **218** using solder, gold (Au) stud bumps, or other fluxless die attach compounds. The combined construction of the spacer **218**, upper scaffold **212**, middle scaffold **220** and vapor cell **214** can then be mounted to a step **209** (e.g., the upper step) of the body **202**. The spacer **218** can be attached to step **209** using solder, gold (Au) stud bumps, or other fluxless die attach compounds. In an example, this die attach can provide both mechanical and electrical feedthru. In another example, this die attach can provide mechanical die attach with no electrical feedthru and the electrical attach can be done with wirebonds.

The lid **204** can be coated with appropriate material (e.g., titanium, etc.) for a getter. In an example, the lid **204** can be coated by sputter depositing the material for the getter. After activating the getter in vacuum, the lid **204** can be sealed to the body **202** with solder.

Although specific embodiments have been illustrated and described herein, it will be appreciated by those of ordinary skill in the art that any arrangement, which is calculated to achieve the same purpose, may be substituted for the specific embodiments shown. Therefore, it is manifestly intended that this invention be limited only by the claims and the equivalents thereof.

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What is claimed is:

1. A chip-scale atomic clock physics package comprising:  
a body defining a cavity including a base surface and one or more side walls, wherein the cavity includes a first step surface and a second step surface defined in the one or more side walls;  
a lid covering an open side of the cavity to enclosed a volume defined by the cavity;  
a first scaffold mounted to the base surface in the cavity;  
a laser mounted to the first scaffold;  
one or more conductive pads on the first step surface;  
one or more wire bonds extending from the first scaffold to the one or more conductive pads, the one or more wire bonds electrically coupling the laser to the one or more conductive pads;  
one or more interconnects disposed within the body and extending from the one or more conductive pads on the first step surface to one or more external pads on an exterior surface of the body;  
one or more spacers defining an aperture therethrough, the one or more spacers having a first surface facing the base surface of the cavity and a second surface facing the lid, wherein the first surface of the one or more spacers is mounted to the second step surface in the cavity;  
a second scaffold mounted to the first surface of the one or more spacers in the cavity and spanning across the aperture of the one or more spacers;  
a third scaffold mounted to the second surface of the one or more spacers in the cavity and spanning across the aperture of the one or more spacers;  
a vapor cell mounted between the second scaffold and the third scaffold and within the aperture defined by the one or more spacers, wherein the vapor cell is mounted to the second scaffold on one side and to the third scaffold on the other side;  
a photodetector mounted to the third scaffold; and  
a waveplate, wherein the laser, waveplate, photodetector, and vapor cell are disposed such that a beam from the laser can propagate through the waveplate and the vapor cell and be detected by the photodetector.
2. The chip-scale atomic clock physics package of claim 1, wherein the lid has a generally planar geometry.
3. The chip-scale atomic clock physics package of claim 1, wherein the third scaffold is disposed in a flipped position with respect to the second scaffold.
4. The chip-scale atomic clock physics package of claim 1, wherein the combination of the one or more spacers and the second scaffold spans the cavity defined by the body, and wherein the combination of the one or more spacers and the third scaffold spans the cavity defined by the body.
5. The chip-scale atomic clock physics package of claim 4, wherein the one or more spacers have a general ring shape, wherein the one or more spacers are attached to opposing sides of the cavity.
6. The chip-scale atomic clock physics package of claim 1, further comprising a magnetic coil about the one or more spacers.
7. The chip-scale atomic clock physics package of claim 1, wherein the body is composed of a ceramic and wherein the one or more spacers are composed of a ceramic.
8. The chip-scale atomic clock physics package of claim 1, wherein the waveplate is mounted to the second scaffold.
9. The chip-scale atomic clock physics package of claim 8, wherein the second scaffold includes a first surface facing the third scaffold and a second surface facing the first scaffold, wherein the vapor cell is mounted to the first surface of the

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second scaffold and the waveplate is mounted to the second surface of the second scaffold.

10. The chip-scale atomic clock physics package of claim 1, wherein the vapor cell is disposed overtop of the photodetector on the third scaffold.

11. The chip-scale atomic clock physics package of claim 1, wherein the one or more external pads are on an external surface of the body opposite the lid.

12. The chip-scale atomic clock physics package of claim 1,  
wherein the one or more spacers include second one or more interconnects extended within the one or more spacers, the second one or more interconnects electrically coupling the second scaffold and the third scaffold to one or more pads on the second step surface,  
wherein the second one or more interconnects electrically couple the one or more external pads to the one or more pads on the second step surface.

13. A chip-scale atomic clock physics package comprising:  
a body defining a cavity;  
a lid covering the cavity;  
a first scaffold mounted in the cavity;  
a laser mounted to the first scaffold;  
one or more spacers mounted in the cavity, the one or more spacers defining an aperture therethrough;  
a magnetic coil integrated within the one or more spacers;  
a second scaffold mounted to the one or more spacers in the cavity and spanning the aperture in the one or more spacers;  
a third scaffold mounted to the one or more spacers in the cavity and spanning the aperture in the one or more spacers;  
a vapor cell mounted between the second scaffold and the third scaffold and within the aperture defined by the one or more spacers, wherein the vapor cell is mounted to the second scaffold on one side and to the third scaffold on the other side;  
a photodetector mounted to the third scaffold; and  
a waveplate, wherein the laser, waveplate, photodetector, and vapor cell are disposed such that a beam from the laser can propagate through the waveplate and the vapor cell and be detected by the photodetector.

14. The chip-scale atomic clock physics package of claim 13, wherein the magnetic coil extends around the vapor cell and is configured to provide a bias field for the vapor cell.

15. The chip-scale atomic clock physics package of claim 13, comprising:  
one or more interconnects extending from external pads on the body to internal pads in the cavity, wherein the magnetic coil integrated within the one or more spacers is electrically coupled to the internal pads such that the magnetic coil is electrically coupled to the external pads through the one or more interconnects.

16. The chip-scale atomic clock physics package of claim 1, wherein the body is composed of a ceramic and wherein the one or more spacers are composed of a ceramic.

17. A chip-scale atomic clock physics package comprising:  
a body defining a cavity;  
a lid covering the cavity;  
a first scaffold mounted in the cavity;  
a laser mounted to the first scaffold;  
a first photodetector mounted to the first scaffold;  
one or more spacers mounted in the cavity and defining an aperture therethrough;  
a second scaffold spanning the cavity and mounted to the one or more spacers in the cavity;  
a waveplate mounted to the second scaffold;

a third scaffold spanning the cavity and mounted to the one or more spacers in the cavity;  
a vapor cell mounted between the second scaffold and the third scaffold and within the aperture defined by the one or more spacers, wherein the vapor cell is mounted to the second scaffold on one side and to the third scaffold on the other side;  
a second photodetector mounted to the third scaffold; and wherein the laser, waveplate, second photodetector, and vapor cell are aligned such that a beam from the laser can propagate through the waveplate and the vapor cell and be detected by the second photodetector, and wherein the first photodetector is disposed to sense reflections from the laser off of the waveplate.

18. The chip-scale atomic clock physics package of claim 17, wherein the first photodetector is disposed such that an output from the first photodetector can be used to determine a power output of the laser, and the power output can be used to control the laser.

19. The chip-scale atomic clock physics package of claim 17, wherein the waveplate is oriented at an angle with respect to the beam from the laser such that reflections from the beam are directed away from the laser, wherein the first photodetector is disposed in accordance with the angle of the waveplate in order to sense the reflections from the waveplate.

20. The chip-scale atomic clock physics package of claim 17, wherein the second scaffold includes a first surface facing the third scaffold and a second surface facing the first scaffold, wherein the vapor cell is mounted to the first surface of the second scaffold and the waveplate is mounted to the second surface of the second scaffold.

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